

# Indications for finite-temperature phase transitions connected with the apparent metal-insulator transition in 2D disordered systems



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1. Introduction / motivation for reanalysis  
of Lai et al., PRB 75 (2007) 033314
2. Empirical situation
3. Comparison with other experiments
4. Scaling analysis
5. Peculiarity at MIT
6. Conclusions

*Out of Equilibrium Quantum Systems, KITP, Santa Barbara, 27.10.2010*

# 1. Introduction / motivation

Fundamental: **Is conduction in two-dimensional system always nonmetallic?**

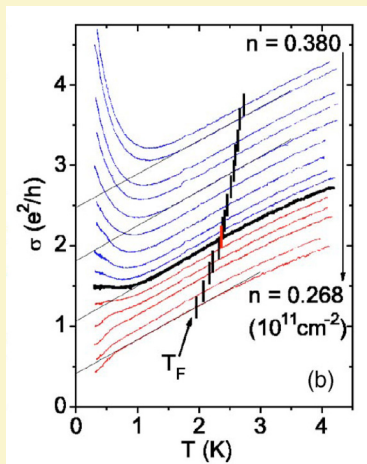
First: theoretical YES by Abrahams et al., 1979, then: experimental NO by Kravchenko et al., 1994. Recent reviews: Kravchenko, Sarachik, 2004, 2010, Spivak et al., 2010. Here: thinking on

PHYSICAL REVIEW B 75, 033314 (2007)

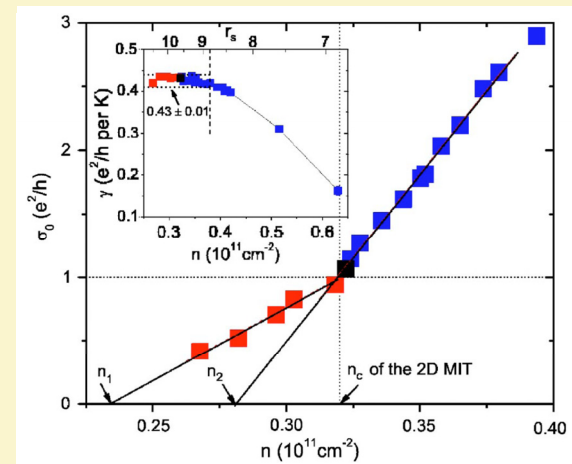
## Linear temperature dependence of the conductivity in Si two-dimensional electrons near the apparent metal-to-insulator transition

K. Lai,<sup>1,\*</sup> W. Pan,<sup>2</sup> D. C. Tsui,<sup>1</sup> S. Lyon,<sup>1</sup> M. Mühlberger,<sup>3</sup> and F. Schäffler<sup>3</sup>

<sup>1</sup>Department of Electrical Engineering, Princeton University, Princeton, New Jersey 08544, USA

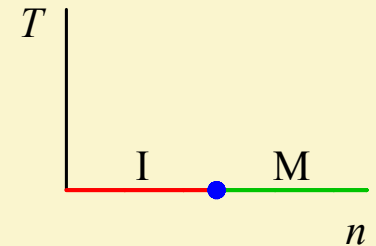


extrapolation  
to  $T=0$



## Results by Lai et al. for $\text{Si}_{0.75}\text{Ge}_{0.25}/\text{Si}/\text{Si}_{0.75}\text{Ge}_{0.25}$ qu. well:

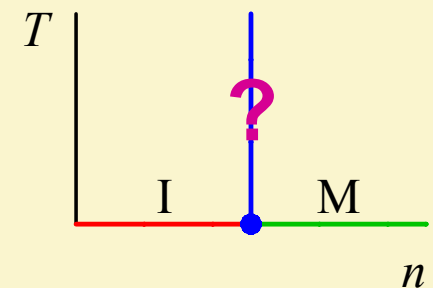
- Extrapolation  $\sigma_0(n)$  exhibits sharp bend (knee), which coincides with critical concentration defined by  $d\sigma/dT=0$  at lowest  $T$ . Thus existence of different phases likely.
- Slope of  $\sigma(T, n = \text{const})$  around  $T_F$  is almost constant.



## Two questions are suggested:

- If  $\sigma_0(n)$  has a knee, and the slope is roughly constant, should not  $\sigma(T = \text{const}, n)$  exhibit a knee for finite  $T$ ?
- If yes, is its existence restricted to the regions of linear  $\sigma(T, n = \text{const})$ , or is it more general phenomenon?

That means: Might there be a phase transition at finite  $T$ ?



## Why would a positive answer be important?

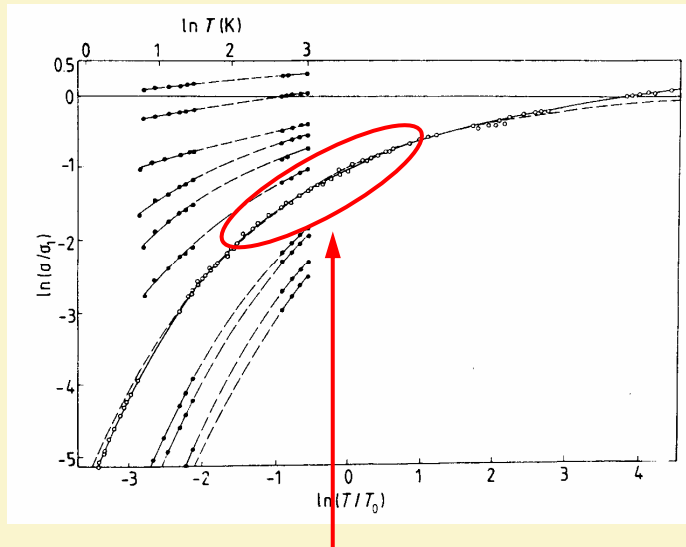
Personal experience from three-dimensional (3D) systems, in particular amorphous transition-metal semiconductor alloys:

Qualitatively, the  $\sigma(T, n)$  curve sets for **2D** and homogeneous **3D** systems (for example Si:P) have a series of **common features**:

- On the “insulating” side, stretched exponential vanishing of  $\sigma(T, n)$  with decreasing  $T$ , which indicates variable-range hopping
- As  $T \rightarrow 0$ , sign change of  $d\sigma/dT$  at and “close to” the metal-insulator transition (MIT) for 2D and 3D systems, respectively.
- Upturn of  $\sigma(T, n)$  with decreasing  $T$  for apparently metallic conduction.
- For arbitrary fixed  $T$ , continuous variation of  $d\sigma/dT$  with  $n$ .

**Common believe in discontinuous MIT for 2D systems**, defined by  $d\sigma/dT = 0$  for  $T \rightarrow 0$ , and **continuous MIT in 3D materials**, defined by  $\sigma(T \rightarrow 0, n) = 0$ .

First doubts in common believe concerning 3D case arise from **scaling** of  $T$  dependence of  $\sigma$  in hopping region for several materials: Provided  $T < T^*$ , if  $\sigma(T, n) < \sigma_0$  then  $\sigma(T, n) = \sigma_0 \varphi(T/T_0(n))$ , where  $T_0(n) \rightarrow 0$  as  $n \rightarrow n_c - 0$ .



Master curve construction for  $a\text{-Si}_{1-x}\text{Cr}_x$   
(AM et al., 1983)

Constancy of prefactor of ES hopping as  $n \rightarrow n_c$   
for Ge:Ga (A.G Zabrodskii, K.N. Zinov'eva, 1984)

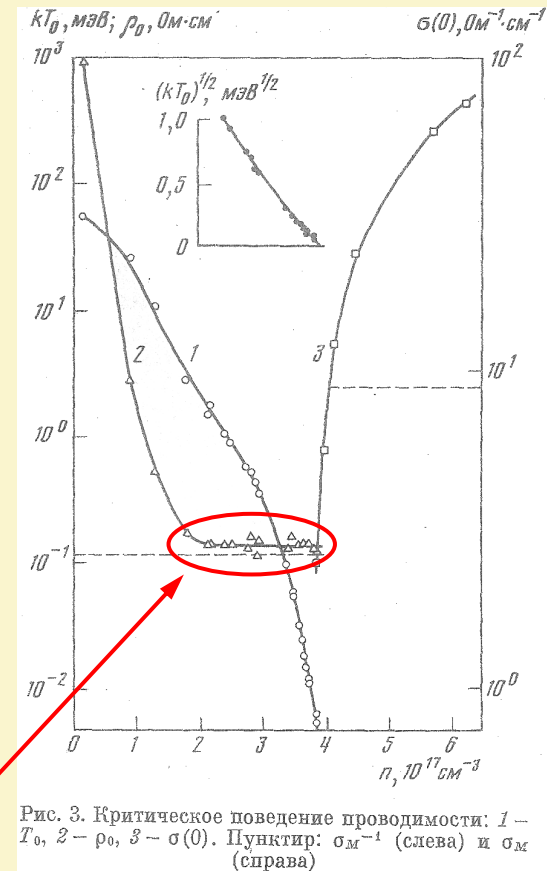


Рис. 3. Критическое поведение проводимости: 1 -  $T_0$ , 2 -  $\rho_0$ , 3 -  $\sigma(0)$ . Пунктир:  $\sigma_M^{-1}$  (слева) и  $\sigma_M$  (справа)

Consequences of  $\sigma(T,n) = \sigma_0 \varphi(T/T_0(n))$ :

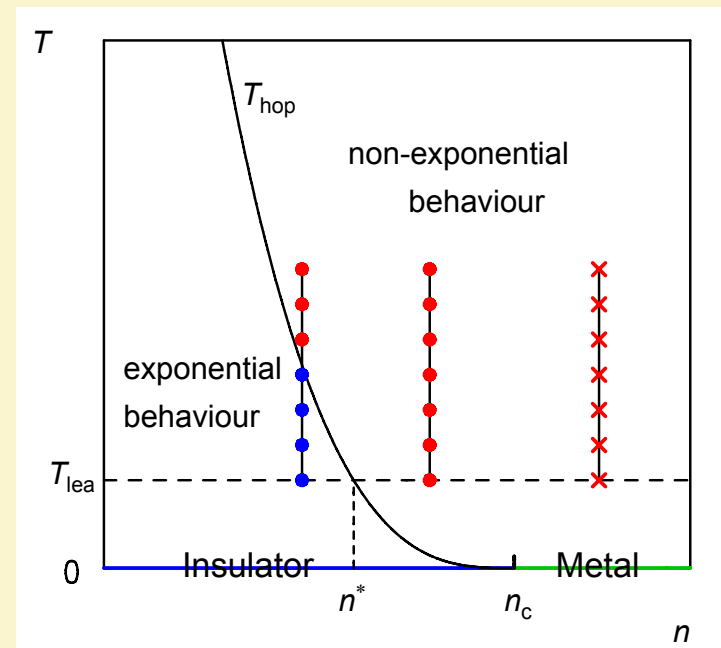
- (i) existence of a minimum metallic conductivity,
- (ii)  $\sigma_0 \varphi(\infty)$  has a special meaning for arbitrary  $T < T^*$ .

However, there is a series of papers claiming continuity of the MIT at  $T = 0$ .

Be cautious:

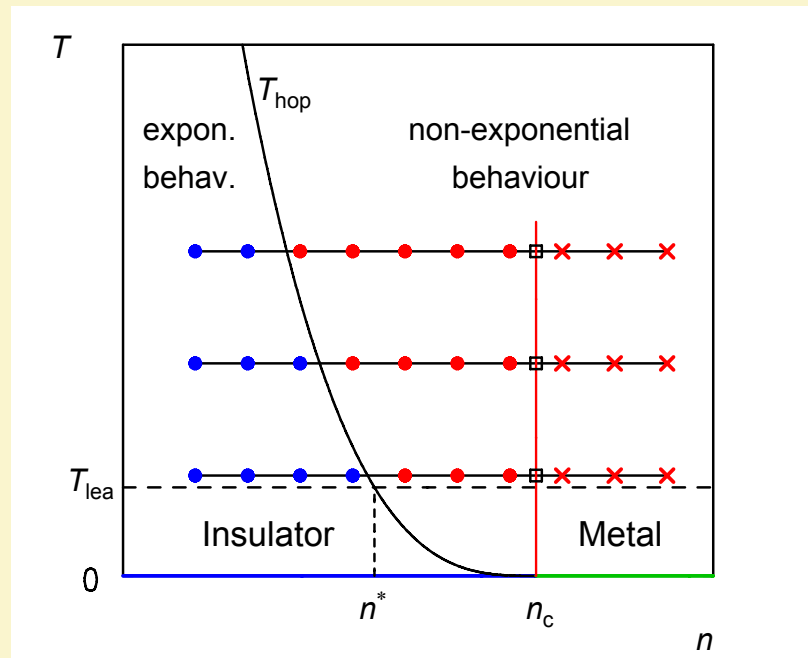
MIT cannot be studied at low  $T$ ,  
since, as it is approached,  
mean activation energy vanishes.

⇒ Not surprising that, in various  
cases, study of  $w = d \ln \sigma / d \ln T$   
causes doubts in  $n_c$  value.



# Dream

Situation will be enormously simplified if the MIT at  $T = 0$  is the endpoint of a line of transitions at finite  $T$ :



⇒ Question: Might nature be so “nice”, at least in the 2D case?

# Additional motivation

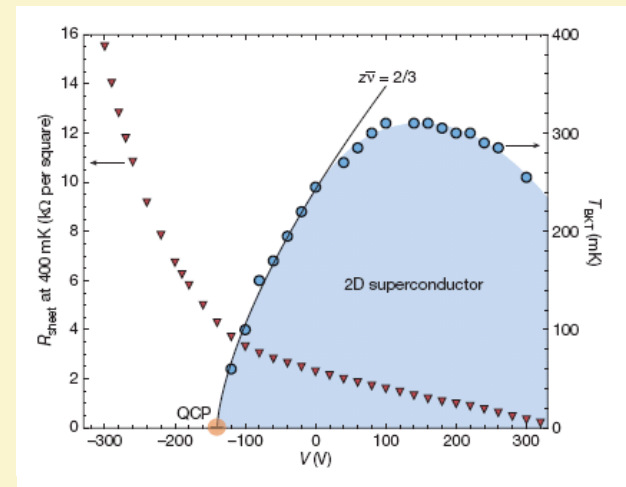
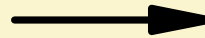
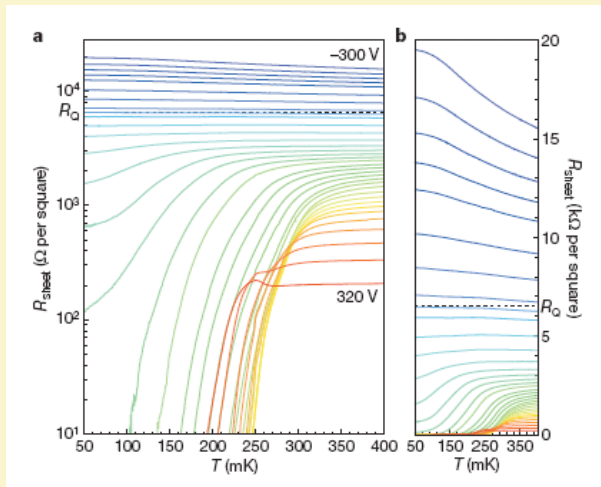
nature

Vol 456 | 4 December 2008 | doi:10.1038/nature07576

LETTERS

## Electric field control of the $\text{LaAlO}_3/\text{SrTiO}_3$ interface ground state

A. D. Caviglia<sup>1</sup>, S. Gariglio<sup>1</sup>, N. Reyren<sup>1</sup>, D. Jaccard<sup>1</sup>, T. Schneider<sup>2</sup>, M. Gabay<sup>3</sup>, S. Thiel<sup>4</sup>, G. Hammerl<sup>4</sup>, J. Mannhart<sup>4</sup> & J.-M. Triscone<sup>1</sup>





## 2. Empirical situation for 2D sample by Lai et al.

Compare two empirical 4-parameter fits:

Piecewise linear,

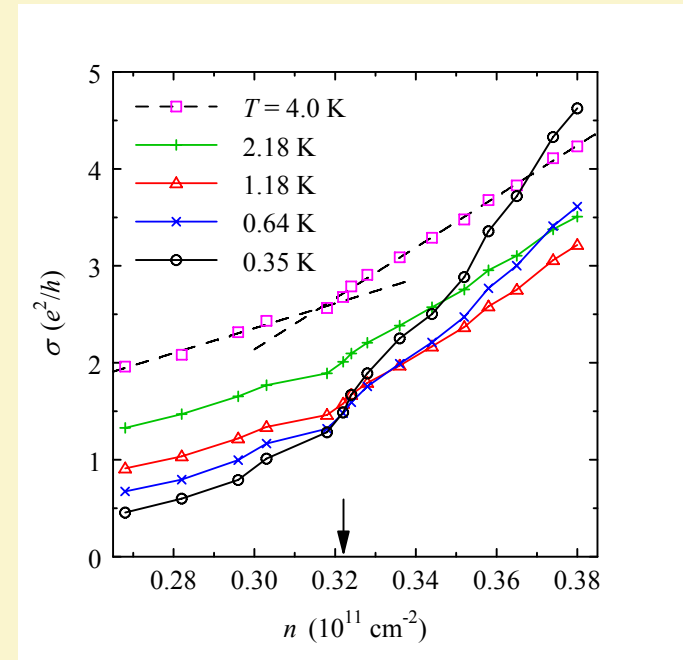
$$f_{\text{plf}} = a + b n + c (n - n_k) \theta(n - n_k) ,$$

and polynomial of third order,

$$f_{\text{pto}} = p + q n + r n^2 + s n^3$$

Results for complete data set:

$T(\text{K})$	$n_k(10^{-11}\text{cm}^{-2})$	$\chi_{\text{plf}}^2(\text{e}^4/h^2)$	$\chi_{\text{pto}}^2(\text{e}^4/h^2)$
4.0	0.318	0.010	0.024
2.18	0.318	0.006	0.019
1.18	0.318	0.010	0.019
0.64	0.318	0.028	0.031
0.35	0.315	0.097	0.063



⇒ **Clear advantage for piecewise linear fit at high  $T$**

## In detail

Problem of comparison:  $\sigma$  range broadens when  $T \rightarrow 0$  and  $\sigma(n)$  is nonlinear at insulator side, vanishes exponentially.  $\Rightarrow$  Fixed  $\sigma$  range is more appropriate.

Results for restricted set,  $0.5 \sigma(T, n_c) < \sigma(T, n) < 2 \sigma(T, n_c)$  :

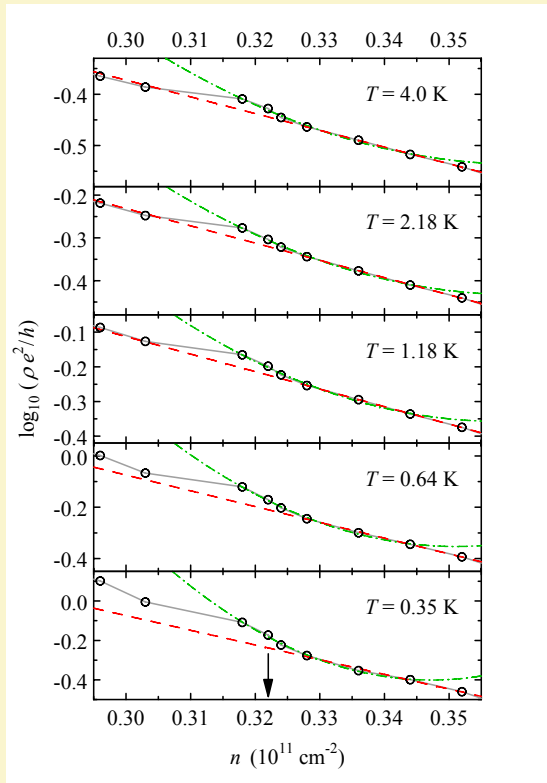
$T$ (K)	$N$	$n_k$ ( $10^{-11} \text{cm}^{-2}$ )	$\chi_{\text{plf}}^2$ ( $e^4/h^2$ )	$\chi_{\text{pto}}^2$ ( $e^4/h^2$ )
4.0	15	0.318	0.010	0.024
2.18	15	0.318	0.006	0.019
1.18	14	0.318	0.009	0.018
0.87	13	0.318	0.009	0.020
0.64	11	0.318	0.013	0.026
0.47	9	0.318	0.023	0.032
0.35	9	0.318	0.024	0.036

$\Rightarrow$  **Piecewise linear function is always clearly better than polynomial.**

$\Rightarrow$  **All knee positions very close to critical concentration from  $d\sigma/dT = 0$ .**

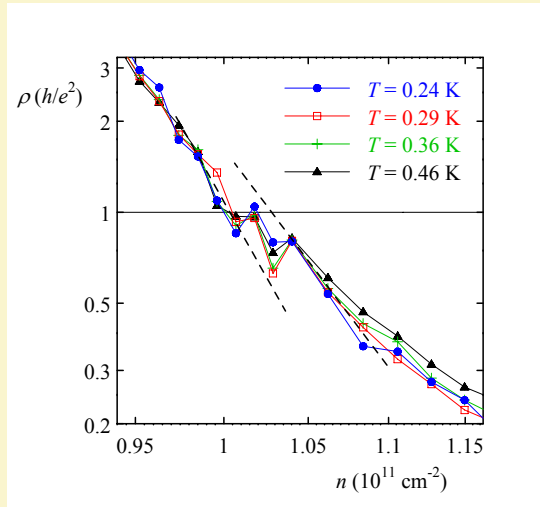
# 3. Comparison with other experiments

Consider usual log-log plots: Data by Lai et al. exhibit “rounded step” for all  $T$ .

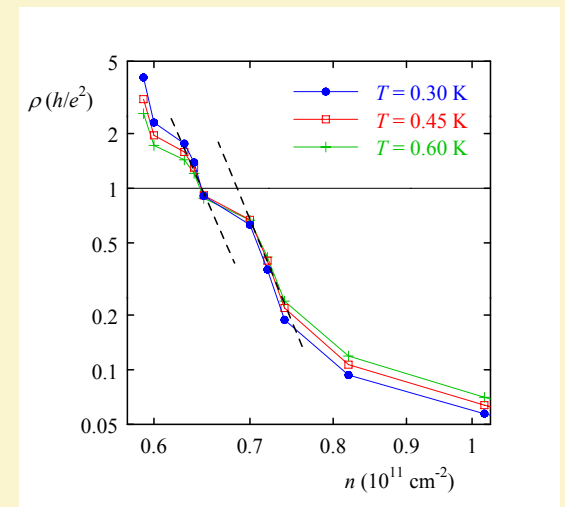


Similar structures were found 2002 in data for

high mobility MOSFET  
by Kravchenko et al.  
(1995)



AIs quantum well  
by Papadakis and  
Shayegan (1998)



# Significance

Peculiarities might arise from random deviations, but it is very unlikely that all following coincidences occur only by chance:

- (a) Observed at **three independent experiments** at different materials.
- (b) Peculiarities have **qualitatively same form** in all three cases.
- (c) Always in **same resistivity region**, slightly below  $h/e^2$ .
- (d) Always **close to common intersection point** of  $\rho(T=\text{const}, n)$  curves.
- (e) Features seem to be present for **all considered  $T$** .

Not found in further experiments, but may be easily overlooked due to inhomogeneities or too small density of the  $n$  values, compare chapter 4.

## 4. Scaling analysis

Suppose,  $\sigma(T, n)$  scales as found at Si MOSFETs by Kravchenko et al.:

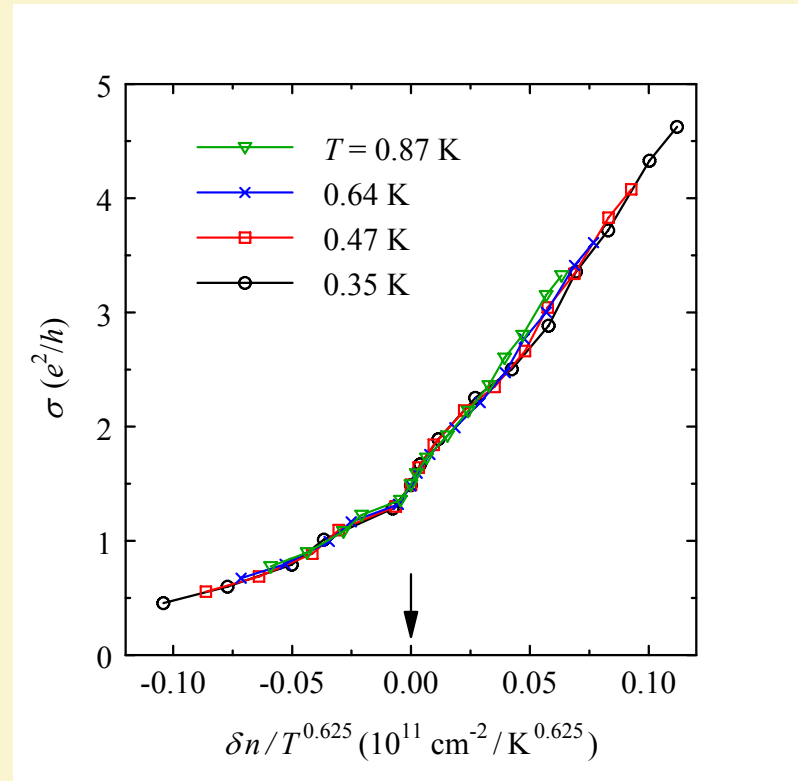
$$\sigma(T, n) = \sigma(t) \quad \text{with} \quad t = T/T_0(n)$$

Assume, scaling holds up to  $n_c$ , where  $T_0$  vanishes, and

$$T_0(n) = A |\delta n|^\beta \quad \text{with} \quad \delta n = n - n_c.$$

Thus,  $\sigma$  should depend only on  $T/|\delta n|^\beta$  or rather on  $\delta n/T^{1/\beta}$ .

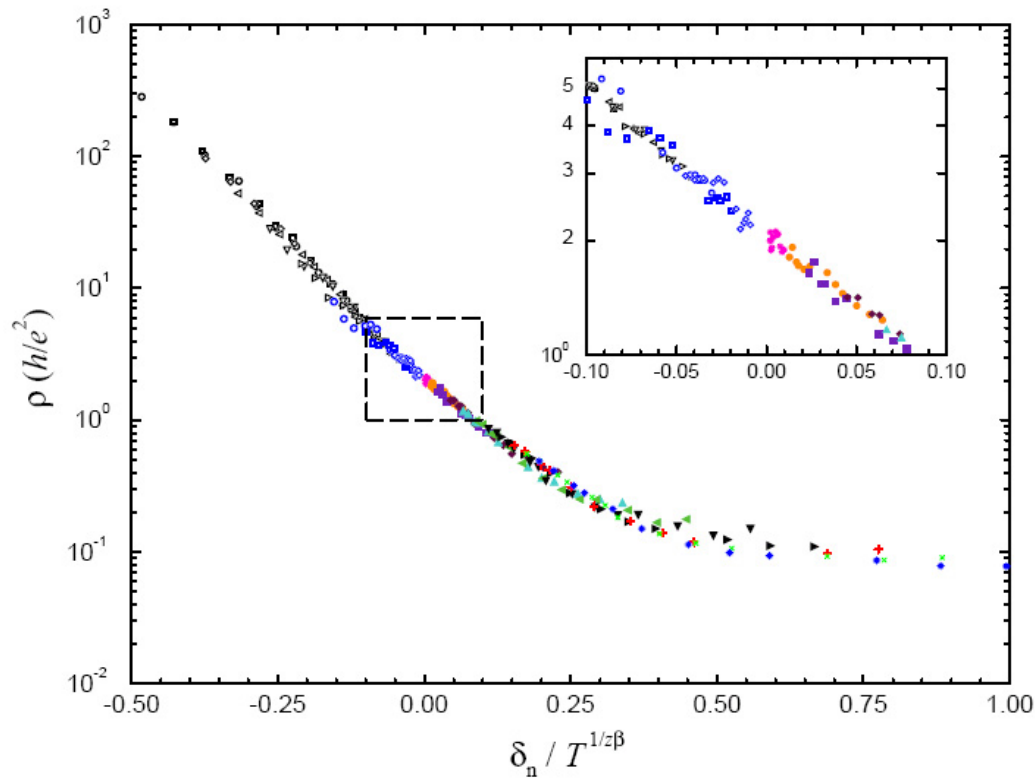
Exponent  $\beta$  should be universal,  $\beta = 1.6 \pm 0.1$  for Si MOSFET.



⇒ **Scaling check without fit passed**

## Scaling from previous work

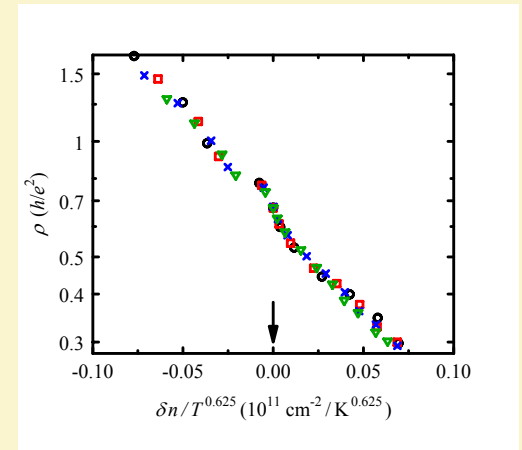
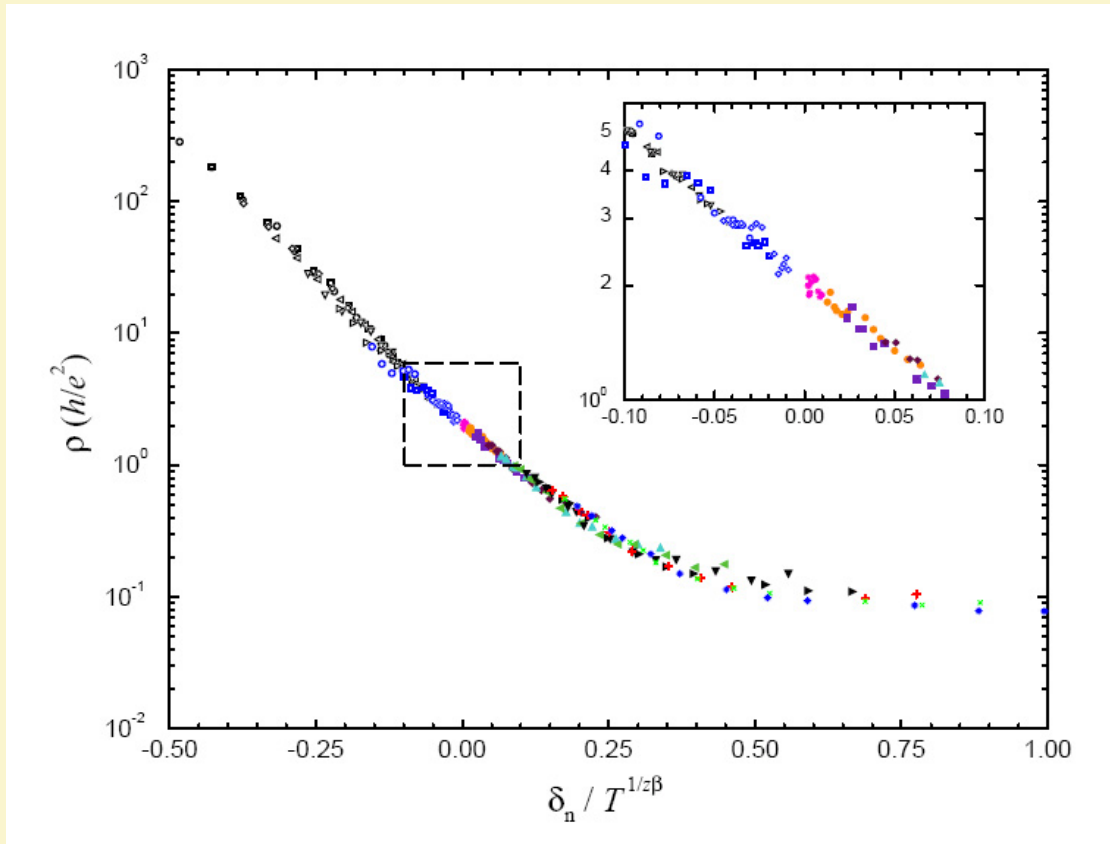
$\rho(T, n)$  instead of  $\sigma(T, n)$  for Si-MOSFET by  
Kravchenko et al. (1995)



# Scaling from previous work

$\rho(T, n)$  instead of  $\sigma(T, n)$  for Si-MOSFET by Kravchenko et al. (1995), in comparison to

data by Lai et al. (2007)



# Remark

Data collapse **without parameter adjustment** is quite convincing, but contains hidden message:

Compare to three-dimensional case: Motivation for scaling analysis from own experiments on amorphous  $\text{Si}_{1-x}\text{Cr}_x$  films. There, scaling only in hopping region. Reason for non-scaling at metallic side:  $x$ -dependence of  $\sigma(T=0, x)$

Here, for  $d=2$ , hint to scaling at both sides of MIT as in Kravchenko's MOSFET study. This feature might imply **new phase**.

**Why?**



In case of conventional metallic conduction, as  $T \rightarrow 0$ :

$\sigma(T, n) \rightarrow$  finite  $\sigma(T=0, n)$ , which increases monotonously with  $n$

Vanishing  $T$  corresponds to diverging  $\delta n / T^{0.625}$ ,

$$\sigma(\delta n / T^{0.625}, n) \rightarrow \sigma(\delta n / T^{0.625} = \infty, n) = \sigma(T=0, n)$$

Thus, curves drawn in scaling plot for varying  $T$  and fixed  $\delta n$  would split, in contradiction to observed scaling.

$\Rightarrow$  Scaling for  $n > n_c$  cannot be understood in terms of conventional metallic conduction. **“Superconductivity” (only) at  $T = 0$**  may be an alternative, compare Kravchenko et al. (1995).

$\Rightarrow$  Data collapse at metallic side = **big puzzle**

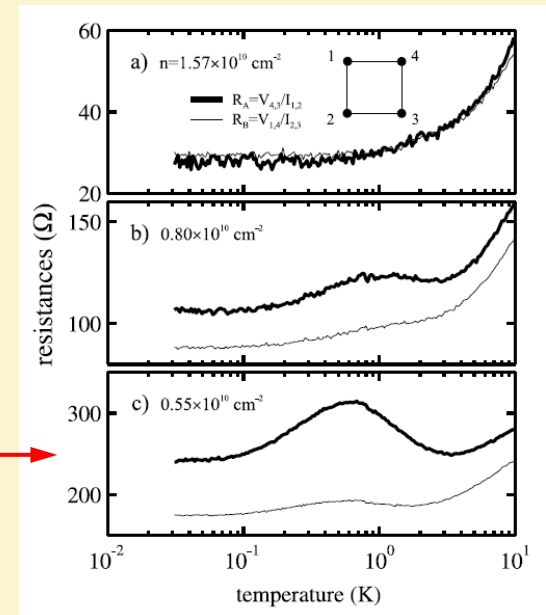
However, saturation at  $n$  dependent  $\sigma$  values as  $T \rightarrow 0$  in many other studies.  
Might, nevertheless, the minority experiments exhibit the generic feature?

Principal problem:

- Unknown validity region of scaling

Possible experimental uncertainties:

- Precision / density of data points,
- thermal decoupling as  $T \rightarrow 0$ ,
- high-temperature mechanism causing apparent  $T$  dependence of  $n_c$ ,
- **inhomogeneities / stress**  $\longrightarrow$   
 $\Rightarrow$  desirable check: van der Pauw  
at samples of different size



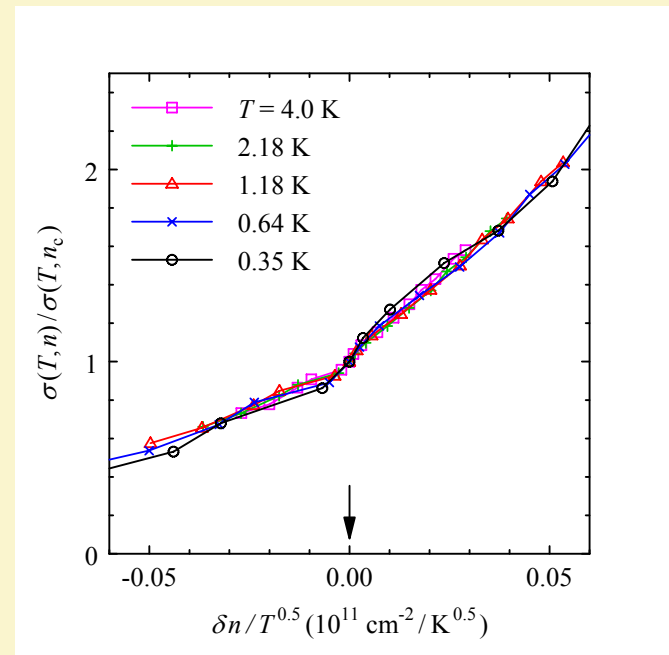
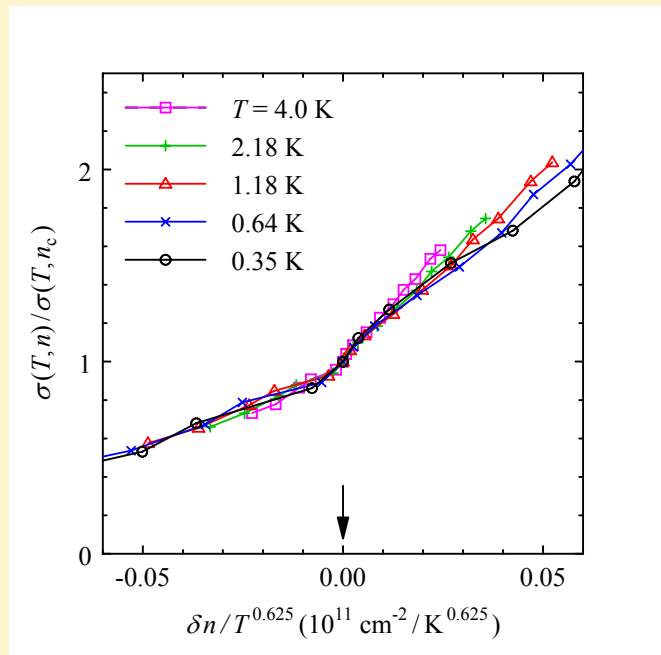
Lilly et al. (2003)

## Generalisation to $T > 1$ K

Let  $T$  increase: Scaling  $\sigma(T, n) = \sigma(t)$  breaks down when separatrix  $\sigma(T, n_c)$  becomes  $T$  dependent. Experience from 3D systems suggests hypothesis

$$\sigma(T, n) = \sigma_{\text{scal}}(T/T_0(n)) \cdot \xi(T/T_1) \quad \text{with } T_1 = \text{const.}$$

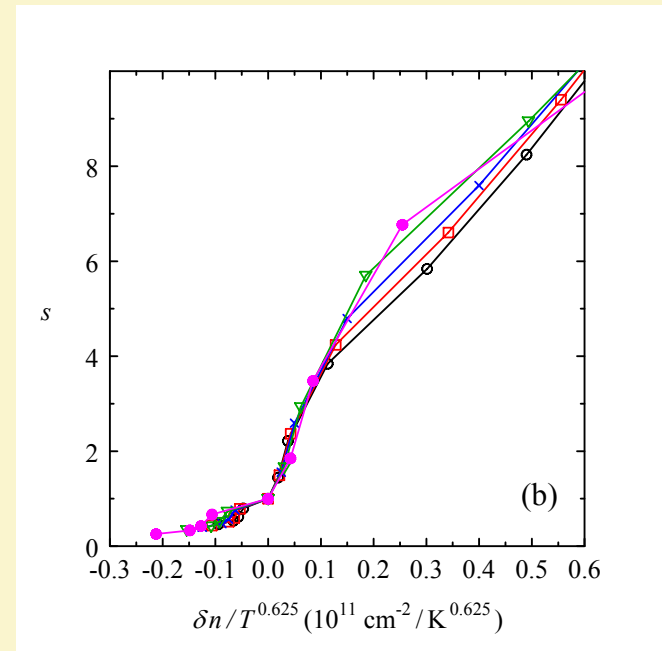
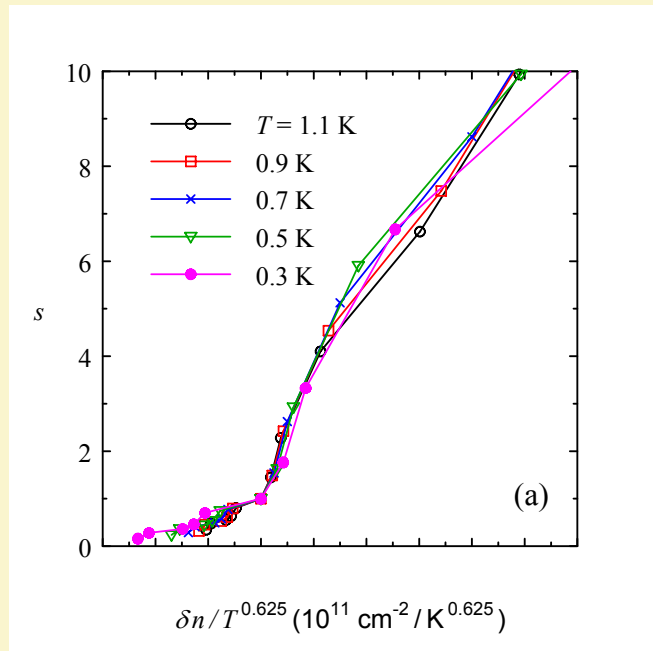
$\Rightarrow s(T, n) = \sigma(T, n) / \sigma(T, n_c)$  may be scaleable. Tests for  $\beta = 1.6$  and 2:



# Comparison to AIAs

Turn once more to data by Papadakis and Shayegan (1998). Focus on  $s(T,n) = \sigma(T,n) / \sigma(T,n_c)$ .

**Hidden problem:** slight uncertainty of critical concentration from measurements for orthogonal directions (a) and (b). Thus, presume  $n_c = 0.70 \cdot 10^{11} \text{ cm}^{-2}$



## 5. Peculiarity at MIT

Possible explanation of indentation  
in  $\sigma(T = \text{const}, n)$  around MIT:

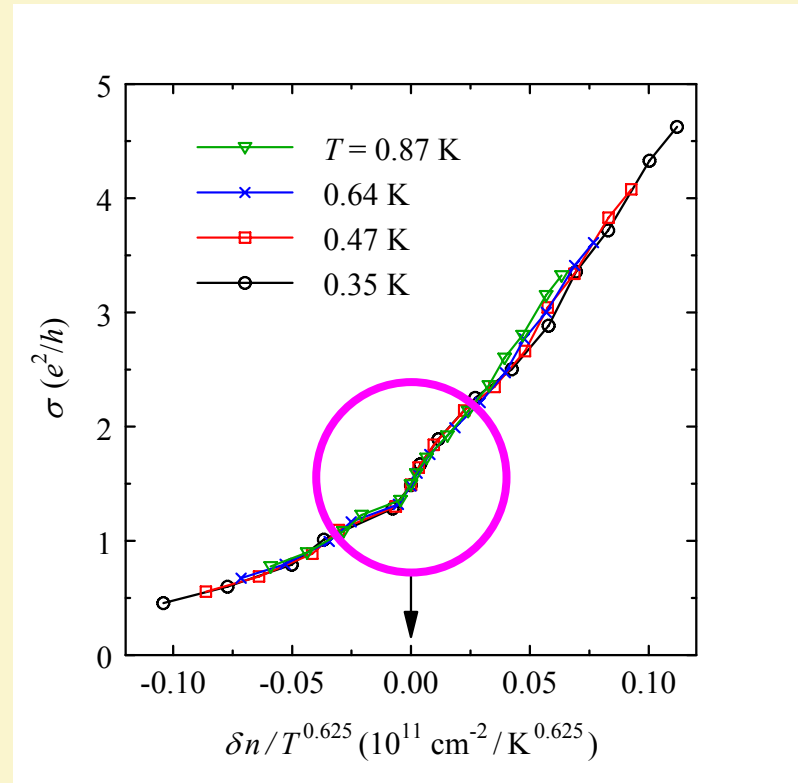
Approach MIT from “insulating” side,  
 $n \rightarrow n_c - 0$ , where  $T_0 \rightarrow 0$  so that  
 $t = T/T_0 \rightarrow \infty$  for all  $T$ . Suppose,

$$\sigma(t) = \sigma_c \cdot (1 - B t^{-\nu})$$

with  $0 < \nu < 1/2$  (hopping). Thus,

$$\sigma = \sigma_c \cdot (1 - C T^{-\nu} |\delta n|^{\beta\nu})$$

with  $\beta\nu < 1$ . Due to this root-like  
peculiarity,  $d\sigma/dn$  should diverge,  
as well as  $d \log_{10} \sigma / dn$ .



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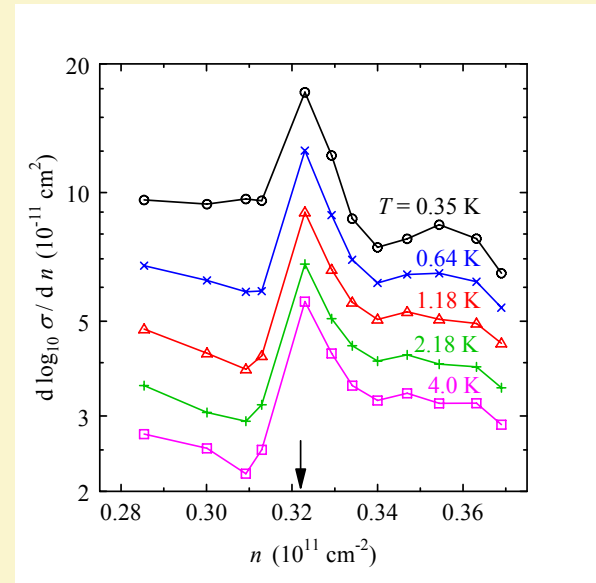
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as well as  $d \log_{10} \sigma / dn$ .



⇒ **Sharp peaks for all  $T$  present**  
(logarithmic scale of ordinate)

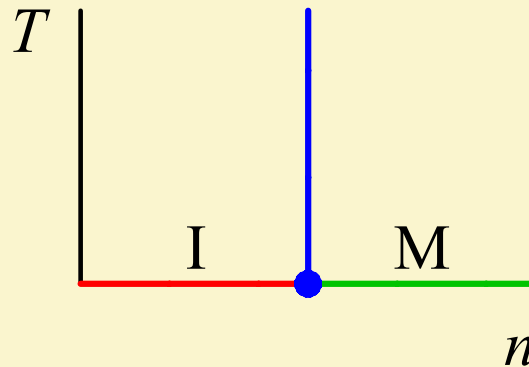
For previous analysis of  $d\sigma/dn(n)$   
compare Mack et al. (1998).

## 6. Conclusions

**Six indications** for line of phase transitions at finite  $T$  connected with the apparent MIT at  $T = 0$ :

- ▶ Advantage of piecewise linear fit compared to power law approximation
- ▶ Knee position close to  $n_c$  and independent of  $T$
- ▶ Similarity to two previous experiments concerning offset in log-log plots
- ▶ Scaling analysis leads to data collapse without fit
- ▶ Quotient  $s(T, n) = \sigma(T, n) / \sigma(T, n_c)$  scales even up to far larger  $T$  than  $\sigma(T, n)$
- ▶ Sharp peaks in  $d \log_{10} \sigma / d n$  as function of  $n$  for all considered  $T$  values

⇒ **Summary:**

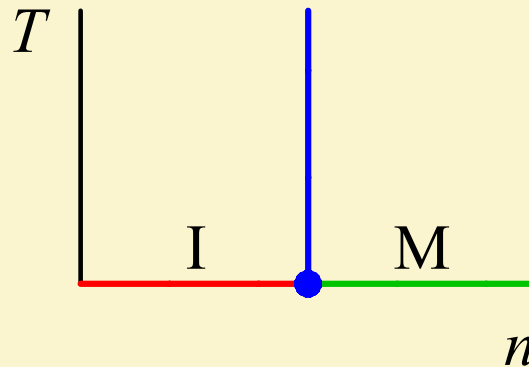


⇒ **Challenges to colleagues:**

- ? Check by independent experiment, **precision matters, not lowest  $T$ :**  
Detection of peculiarity in  $\sigma(T = \text{const}, n)$  should at larger  $T$  be simpler.  
Consider argument of scaling function  $\sigma(x)$ ,  $x = \delta n / T^{1/\beta}$ , experimental uncertainties  $\Delta n$  and  $\Delta T$ . Thus:  $|\Delta x| = |\Delta n| / T^{1/\beta} + (|\Delta T| / T) |x| / \beta$
- ? Nature of apparently metallic phase



⇒ **Summary:**



⇒ **Challenges to colleagues:**

- ? Check by independent experiment, **precision matters, not lowest  $T$** :  
Detection of peculiarity in  $\sigma(T = \text{const}, n)$  should at larger  $T$  be simpler.  
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- ? Nature of apparently metallic phase

For details: AM, Phys. Rev B **77** (2008) 205317; Physica E **42** (2010) 1243

**Thank you for your attention!**